



A35109-PCT-USA - 067515.0161

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Bong-Cheol Kim
Serial No. : 10/089,479 Examiner : David Nhu
Filed : March 28, 2003 Group Art Unit : 2818
For : APPARATUS AND METHOD FOR FORMING SINGLE
CRYSTALLINE NITRIDE SUBSTRATE USING HYDRIDE
VAPOR PHASE EPITAXY AND LASER BEAM

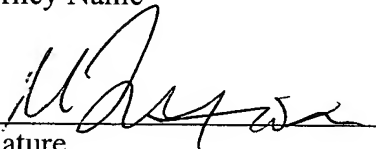
REPLY TO OFFICE ACTION

I hereby certify that this paper is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P. O. Box 1450, Alexandria, VA 22313-1450.

September 26, 2003
Date of Deposit

Manu J. Tejwani
Attorney Name

37,952
PTO Registration No


Signature

September 26, 2003
Date of Signature

Commissioner of Patents
P.O. Box 1450
Alexandria VA D.C. 22313-1450

Sir:

In reply to the Office Action dated May 29, 2003, applicant amends claims as listed in the Claims section (page 2), and amends the specification as listed in the Amendments to the Specification section (page 5). A Replacement Drawing sheet is enclosed as described in the Amendments to Drawings section (page 8). Remarks are presented at page 9 of this paper.